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Experimental realization of ultrathin, double-sided metamaterial perfect absorber at terahertz gap through stochastic design process

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We design and demonstrate a flexible, ultrathin and double-sided metamaterial perfect absorber (MPA) at 2.39 terahertz (THz), which enables excellent light absorbance under incidences from two opposite sides. Herein, the MPA is fabricated on a $\lambda_0/10.1$ -thick flexible polyethylene terephthalate substrate of $\epsilon_r = 2.75 \times (1 + 0.12i)$, sandwiched by two identical randomized metallic patterns by our stochastic design process. Such an MPA provides tailored permittivity and permeability to approach the impedance of free space for minimizing reflectance and a great imaginary part of the refractive index for reducing transmittance and finally results in high absorbance. Both experimental measurement and numerical simulation are in a good agreement. The flexible, ultrathin and double-sided MPA significantly differs from traditional quarter-wavelength absorbers and other single-sided perfect absorbers, paving a way toward practical THz applications in thermal emission, sensing and imaging, communications, stealth technique, and even energy harvesting.

First introduced by W. J. Padilla *et al.* in 2008¹, metamaterial-based perfect absorbers (MPAs) have soon attracted researchers' attention due to their abilities to significantly suppress the thickness of the absorbers into a sub-wavelength scale, $\lambda_0/35$ and $\lambda_0/33$ (excluding 500- μm -thick GaAs substrate) at microwave and terahertz regions^{1,2}, respectively, in contrast to the traditional Salisbury or Jaumann screens with the thicknesses of quarter-wavelengths for single or multiple radar frequencies. An MPA is typically comprised of two distinct metallic layers with a dielectric spacer. There correspond two keys to design these two metallic layers— one is to design the first metallic layer and then tailor constitutive parameters (i.e., ϵ and μ) of entire unit cell to approach free space impedance for minimizing reflectance (R); the other is to employ a back reflector as the second metallic layer, such as a plasmonic line² or a metallic ground plane^{3–7}, for blocking transmittance (T). Once both of reflectance and transmittance are minimized, one can certainly maximize the absorbance (A; $A = 1 - R - T$). Based on these two keys, recently several MPAs have been demonstrated, such as broadband^{3–5}, wide-angle⁶ and polarization insensitive⁷ absorbers. Yet, the employment of the back reflector essentially sets a constraint on the incident direction into the single one. For example, if waves impinge from the side of the back reflector, then the wave will not be absorbed but reflected by this MPA. In this case, a perfect absorber suddenly becomes a perfect reflector, which plagues the practical applications.

More recently, an alternative design termed as metasurfaces has been reported to absorb light^{8–10}. By introducing a phase shift from the metasurfaces, the multi-reflected waves destructively interfere with each other, reducing a reflectance down to 0.25%, and the transmitted wave is completely absorbed by adjusting the optical loss of the

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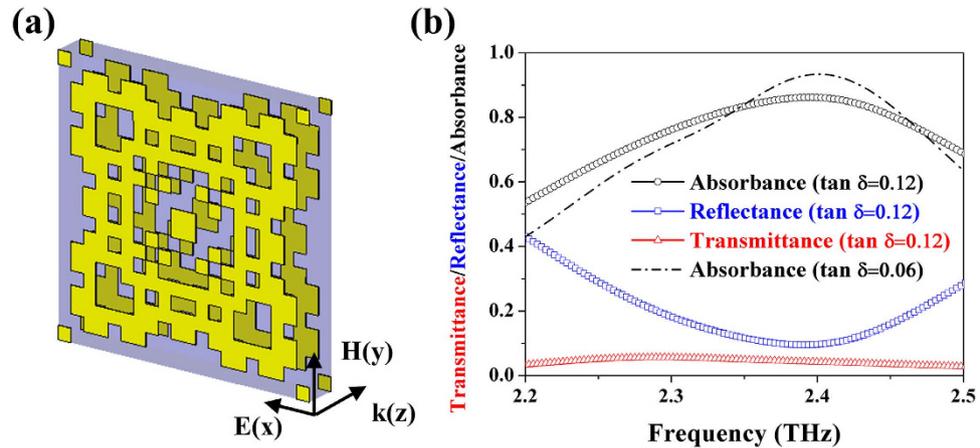


Figure 1. A double-sided metamaterial perfect absorber (MPA) and its performance. (a) A schematic view of a double-sided MPA with metallic patterns developed through a stochastic process. In simulation, we set the unit cell boundary conditions in the both x and y -directions to emit a plane wave with the polarization oriented in the x direction. (b) Simulated reflectance (blue symbols), transmittance (red symbols), and absorbance (black symbols) of the double-sided MPA. The substrate is a flexible polyethylene terephthalate (PET) thin film of $12\text{-}\mu\text{m}$ -thick, with loss tangent ($\tan \delta$) of 0.12. The corresponding reflectance and transmittance are 9.5% and 4.3%, respectively, resulting in a remarkable absorbance of 86.2% at 2.39 THz. One can further intensify the absorbance by employing a less lossy PET film (e.g., 93.4% for $\tan \delta = 0.06$).

optical thin film. Still, this kind of metasurfaces encounters the same limitation of single-sided applications, like conventional MPAs do. Another route to absorbing light can be achieved by means of transformation optics to construct an optical black hole^{11–13}. Unfortunately, this optical black hole is especially bulky under grazing angle incidence. As a consequence, to address the challenges abovementioned, in this work we introduce a flexible, ultrathin and double-sided MPA at the terahertz (THz) gap on the basis of the effective medium theory^{14,15}. Through our developed computer-aided stochastic design process, we can efficiently acquire patterns with the absorbance close to unity under bi-directional incidences, yielding practical applications including thermal emitters¹⁶, focal planar array imaging^{17,18}, plasmonic sensors¹⁹, communication devices²⁰, stealth materials²¹ and even energy harvesting materials²².

Results

Patterns of double-sided metamaterial perfect absorber from stochastic design process. The double-sided MPA is comprised of a metal-insulator-metal (MIM) structure. For the insulating substrate, we utilized a flexible polyethylene terephthalate (PET) thin film with the electric permittivity (ϵ_r) of $2.75 \times (1 + 0.12i)$ and the thickness of $12\text{ }\mu\text{m}$, about $\lambda_0/10.1$ -thick. As for the metallic pattern of the double-sided MPA, it is worth mentioning that it is not achievable by simply copying the front pattern to replace the back-reflector in cases of conventional MPAs^{23,24}. To conquer this obstacle, we develop a stochastic process to design the metallic patterns on the two sides. In this stochastic process, the metallic patterns are developed through discretizing the unit cell into 20×20 pixels with the pixel size of $5 \times 5\text{ }\mu\text{m}^2$ (i.e., unit cell size equal to $100 \times 100\text{ }\mu\text{m}^2$). In addition, we only consider the one eighth of the metallic pattern in the unit cell to create a four-fold symmetric pattern by mirroring the generated patterns three times to achieve the polarization-insensitive performance. Then, we randomized a value between 0 and 1 to determine whether or not there exists metal on a pixel (see Method for more details). By repeating this random process on each pixel, we could obtain the metallic patterns capable of double-sided absorbance. Note that the stochastic design process could be the very first step of the genetic algorithm, thus possessing a potential to further optimize the performance of the MPA through targeted goals in a genetic algorithm^{25–28}. Finally, among two thousand stochastic patterns, the best design of the double-sided MPA is presented in Fig. 1(a). To testify the performance of our double-sided MPA, we employed a finite-integration simulation method, *CST Microwave Studio*TM, to numerically calculate the corresponding reflectance, transmittance and absorbance. In simulation, we choose build-in material properties of gold with conductivity of $4.56 \times 10^7\text{ S/m}$, which is sufficient for simulation within terahertz region⁷. As shown in Fig. 1(b), the reflectance and transmittance equal to 9.5% and 5.3% at 2.39 THz, respectively, indeed leading to an absorbance peak of 86.2% within the THz gap. More importantly, the absorbance would further elevate up to 93.4% as shown in Fig. 1(b) once a PET film with less loss tangent ($\tan \delta$), for example, equal to 0.06 is available for the experiment (see Fig. S1 and Fig. S2 in Supplementary Information for further discussion).

Surface currents and field distribution. The mechanism of the double-sided MPA can be clarified by scrutinizing the current distributions within the metallic pattern. As shown in Fig. 2(a,b), there exist the parallel currents, flowing within each metallic pattern (labeled by the white arrows on each side). These parallel currents support the excitation of the electric dipoles, modulating the effective electric permittivity; meanwhile, there also appear anti-parallel currents flowing between two metallic layers (labeled by the red arrows), which enable the excitations of the magnetic dipoles, giving rise to the demanded magnetic permeability in the nonmagnetic

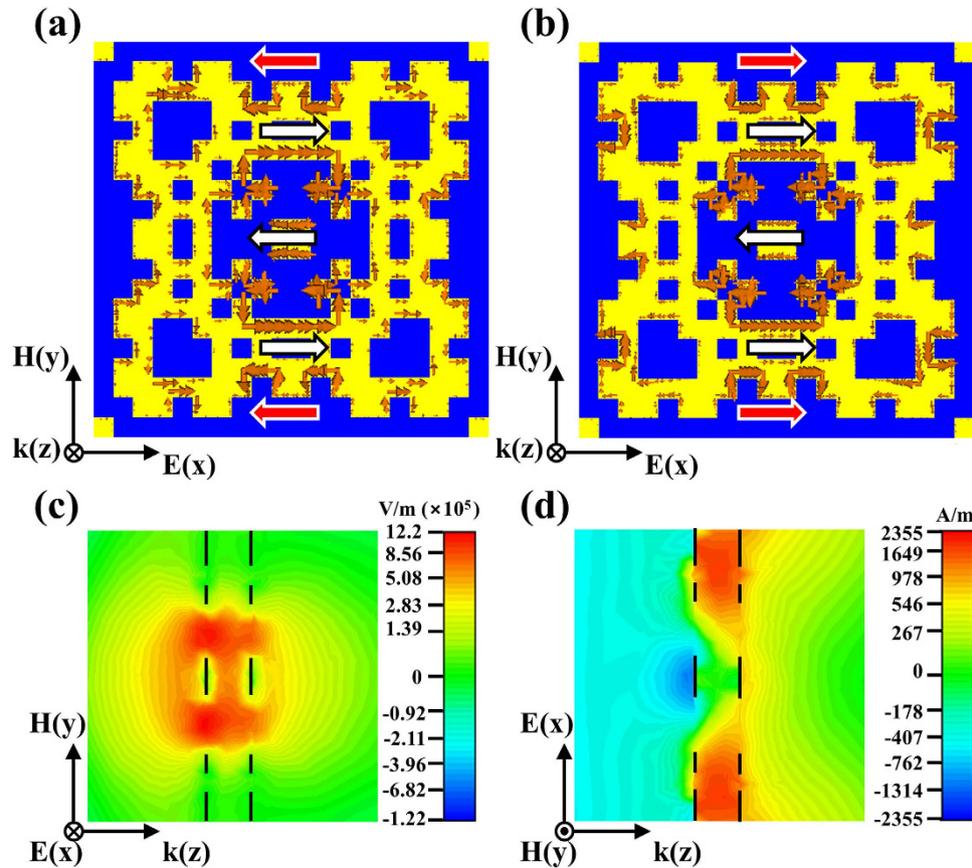


Figure 2. Surface current and field distributions of the double-sided MPA. Top views of the surface current distribution (a) on the first metallic patterns and (b) on the second metallic pattern. The currents on the first and second metallic patterns exhibit a pair of anti-parallel currents (denoted by the red arrows) resulting in a magnetic response at the certain area. On the other hand, the parallel surface currents on each surface demonstrate an electric response (indicated by white arrows). Side views of the (c) electric field and (d) magnetic field distributions present localized fields concentrating mainly within the PET and near the metallic patterns.

materials to balance the impedance between the MPA and free space. Moreover, we observe that both of the electric and magnetic fields are mainly localized within the dielectric layer and few adjacent to the metallic patterns, indicated in Fig. 2(c,d). Such localized electromagnetic fields dissipating in the spacer might benefit the field of energy harvesting when PET is replaced by semiconductor^{29,30} (see Fig. S3 in Supplementary Information for more details).

Retrieval data of complex electric permittivity, magnetic permeability and refractive index. To further comprehend the mechanism of the double-sided MPA, we employed the conventional sophisticated retrieval method to extract the complex permittivity, permeability and effective refractive index, respectively^{14,15}. The real part of permittivity and permeability are intersected around 2.39 THz as shown in Fig. 3, resulting in a minimized reflectance by matching the impedance to the one of free space. Moreover, the imaginary part of the index presents an enhanced value of 0.72, which is almost 7 times larger compared to the intrinsic losses of the PET film itself; thus, the proposed double-sided MPA could absorb the incident energy and then give rise to low transmittance. Therefore, according to the retrieval data, suggesting the matched impedance and enhanced imaginary part of the index, we could predict an absorption peak occurs at 2.39 THz in the double-sided MPA, which is consistent with the simulated spectrum as portrayed in Fig. 1(b). It is worthy stating that we also employ the multiple reflection theory to explain the behavior of our proposed perfect absorber as suggested in ref. 24, but we can only achieve a similar response after irrationally increasing the corresponding losses of the substrate by 100 times; moreover, the reduction of reflection stems from the matched impedance rather than the destructive interference suggested by the multiple reflection theory due to the fact that the direct reflection itself is small enough compared to the overall reflection with minor influences from the consecutive multiple reflection. Thus, we claim that the enabling factor of our double-sided MPA originated from the matching impedance and great effective propagating losses of the spacer evidenced by the effective medium theory instead of the multiple interference theory.

Sample fabrication and characterization. For the sample fabrication, we applied an ultraviolet (UV) lithography technique and an electron-gun deposition process, and then a lift-off technique to realizing the

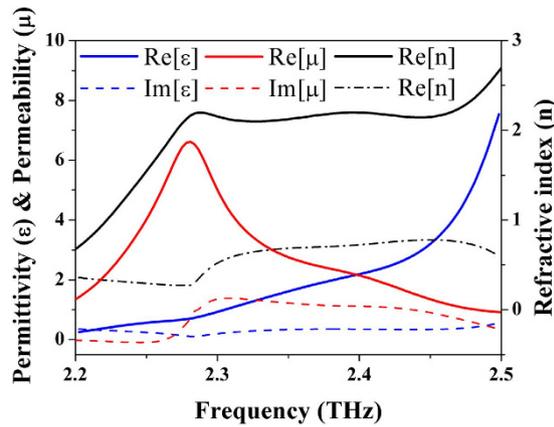


Figure 3. Retrieval data of the double-sided MPA. The retrieval data implies a matching impedance and great imaginary part of index leading to minimum reflectance and transmittance, respectively at the frequency of absorbance maximum, i.e., 2.39 THz.

designed metallic pattern. Since both of the rotation and translation alignment between the two metallic patterns of the double-sided MPA are a request to ensure the functionality of the structure, we also employed an alignment mark to provide 2- μm accuracy. The fabricated structure is comprised of 10-nm-thick titanium (as an adhesion layer) and 200-nm-thick gold films, and its unit cell is shown in the upper part of Fig. 4(a). Besides, we adopted a commercially available PET film as a dielectric spacer. This flexible PET film is 12- μm -thick, about a tenth of the working wavelength with a complex dielectric constant $\epsilon_r = 2.75 \times (1 + 0.12i)$. Finally, a flexible, ultrathin, optically transparent and double-sided MPA is presented in the middle and lower parts of Fig. 4(a).

Next, we characterized the performance of the fabricated MPA by a micro-Fourier transform infrared ($\mu\text{-FTIR}$) spectrometer (Vertex 70V) in the frequency range from 2.2 to 2.5 THz. Notice that we conducted the reflectance measurement at 11° instead of normal incidence, and in this case, there appear two different conditions of TE and TM incidences. As shown in Fig. 4(b,c), the measured absorbance is up to 78.6% for the TE incidence and 80.8% for the TM incidence, respectively. Such similar values of absorbance for two different incidence cases reflect that the MPA is insensitive to polarization due to its 4-fold symmetric design. Herein a great portion of loss originates from the PET film, so that one can enhance the absorbance over 90% as predicted in the simulation (see Fig. 1) by simply using a more transparent film. In addition, we also characterized the performance of the MPA, under the incidence from the other side. The corresponding results are shown in Fig. 4(d,e). As we expected, these results are similar to prior Fig. 4(b,c), indicating that this MPA is indeed a double-sided device. Note that all the results shown in Fig. 4(b–e), including the experiment (solid lines) and the simulation (dashed line) are in an excellent agreement. The little offset between the experiment and the simulation results from the fabrication imperfection, mainly caused by the uncontrollable flatness of the 12- μm -thin and flexible PET substrate.

Finally, the fabricated double-sided MPA is ultrathin, with sub-wavelength thickness of $\lambda_0/10.1$, where λ_0 is the free space wavelength. In fact, we could further reduce the thickness of the double-sided MPA once we obtain a thinner substrate in stock (see Fig. S4 and Fig. S5 in Supplementary Information for discussion of thickness- and angle-dependence of our double-sided MPA).

Discussion

In conclusion, we have stochastically developed metamaterial patterns to successfully demonstrate an MPA within the THz gap. At 2.39 THz, we demonstrated remarkable absorbance up to 80.8%, under the 11° off-normal incidence in $\mu\text{-FTIR}$ measurement. The enabling factors of this MPA are minimizing the reflectance by approaching impedance-matching between free space and the MPA, and diminishing the transmittance by maximizing effective imaginary part of refractive index of the MPA, respectively. Different from other absorbers, the demonstrated sample can be operated for both-side applications, and is flexible and ultrathin with the thickness of $\lambda_0/10.1$ that can be further miniaturized by employing a thinner flexible thin film. In addition, the field distributions within the metallic pattern and the dielectric spacer of the MPA indicate that the major energy is absorbed within the dielectric layer, instead of dissipated as heat in the metallic pattern. Therefore, not only this absorber can be readily employed for thermal emission, sensing/imaging, communications and stealth technique, but it could also facilitate harvesting photon energy.

Methods

Stochastic design process. In the first step of the stochastic design process, a unit cell of the double-sided metamaterial perfect absorber (MPA) is divided into 20×20 square pixels and then whether there would appear a metallic pattern on the front and back sides of each pixel or not depends on a randomized number between 0 to 1. Once the random number is smaller than 0.5, there would not appear metal on that pixel; otherwise, there would exist metallic squares on both sides. Further, in order to achieve a polarization-independent pattern, we only encode one eighth of total 400 pixels and generate a four-fold symmetric pattern by mirroring the one-eighth pattern three times. Thus, by repeating the random process on the one-eighth pixels 55 times, we can easily achieve

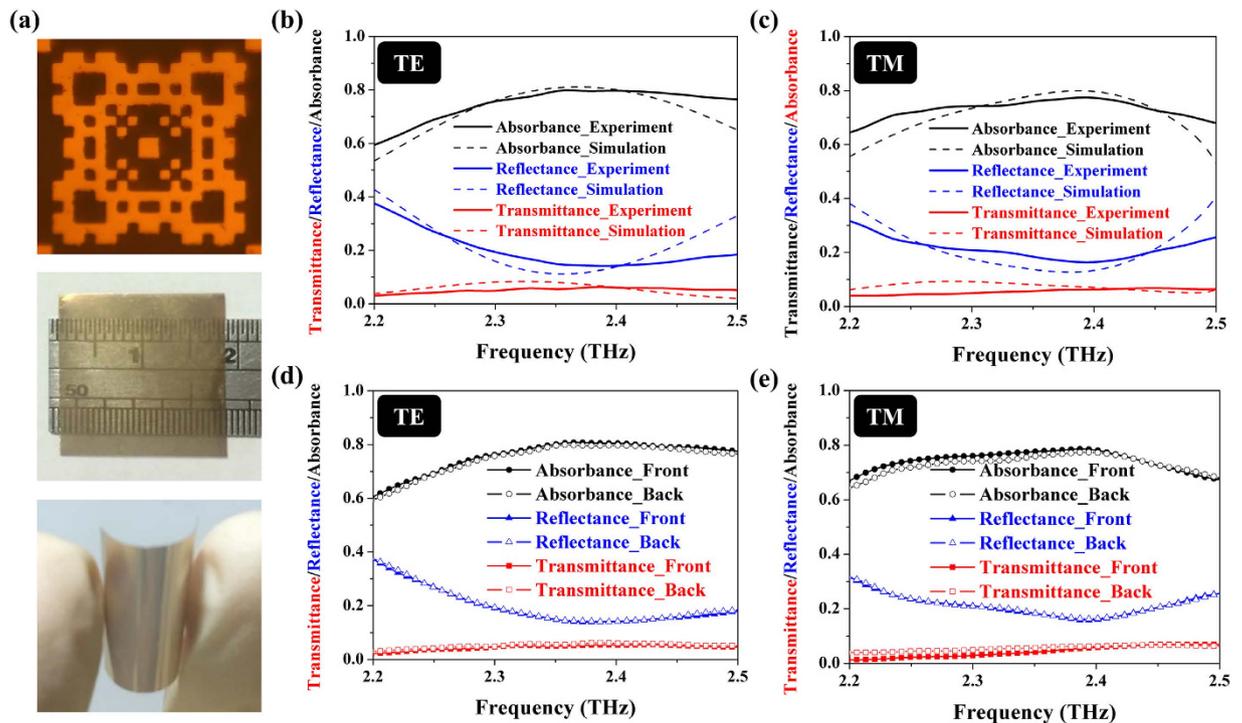


Figure 4. Experiment results of the double-sided MPA. (a) Optical microscope image of the unit cell, the photograph of $18 \times 18 \text{ mm}^2$ fabricated samples and the bent sample showing the flexibility. Clearly, the double-sided PA is transparent at the visible range. Experimental (solid line) and simulation (dashed line) results of the double-sided PA in (b) TE and (c) TM incident conditions. The two reveal an excellent agreement. Moreover, the double-sided absorption is demonstrated by the experiments at both the front-sided (solid symbols) and back-sided (hollow shape) incidences for (d) TE and (e) TM cases as well.

a stochastic designed double-sided MPA whose performance is further determined in the aid of the commercial electromagnetic solver of the finite integration method.

Sample fabrication.

1. Designed photo-mask of metamaterial pattern from stochastic process
2. Attached $12\text{-}\mu\text{m}$ -thick PET on Si substrate
3. Conducted UV photolithography
4. Deposited 10 nm -thick titanium and 200 nm -thick gold
5. Proceeded Lift-off process
6. Flipped the $12\text{ }\mu\text{m}$ -thick PET with first pattern
7. Repeated step1–6 for the second pattern with tolerable alignment on the other side

Measurement.

Micro-Fourier transform infrared ($\mu\text{-FTIR}$) spectrometer (Vertex 70V)
 Light source: Mercury lamp
 Spectral range: $100\text{--}10\text{ cm}^{-1}$
 Spectral resolution: 1 cm^{-1}
 Aperture size: 8 mm
 Scan velocity: 1.6 kHz

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Author Contributions

T.-J.Y. conceived the project, T.-Y.H. and C.-W.T. developed the stochastic design process, T.A. provided the possible feasibility of the structure from stochastic process, C.-W.T. and T.-T.Y. simulated, fabricated, and measured the samples. T.-Y.H. and T.-T.Y. also analytically calculated the retrieval data. T.-T.Y. and C.-W.L. installed the 11° module of FTIR measurement and assisted with the measurement. T.-J.Y., T.-Y.H. and T.-T.Y. co-wrote the paper. All authors discussed the results and commented on the manuscript.

Additional Information

Supplementary information accompanies this paper at <http://www.nature.com/srep>

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